

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
L1	100411	liquid with top	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/05/11 18:50
L2	9075	1 and (semiconductor wafer microelectronic)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/05/11 18:50
L3	4373	2 and (anode cathode electrode)	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/05/11 18:52
L4	1480	3 and sealing	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/05/11 18:52
L5	855	3 and sealing	USPAT	OR	ON	2005/05/11 18:52
L6	154	4 and (washing rinsing)	USPAT	OR	ON	2005/05/11 19:08